

Docket No. 214768US90PCT

IN RE APPLICATION OF: Yasuji HIRAMATSU, et al

SERIAL NO: 09/926,297

FILED: December 26, 2001

FOR: CERAMIC SUBSTRATE FOR A SEMICONDUCTOR-PRODUCTION/INSPECTION DEVICE



281-2  
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ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

SIR:

Transmitted herewith is an Amendment with marked-up copy in the above-identified application.

- ☐ No additional fee is required
- ☐ Small entity status of this application under 37 C.F.R. §1.9 and §1.27 is claimed.
- ☒ Additional documents filed herewith: Petition for Extension of Time; Pages 36-37 of specification (Tables 1 and 2)

TECHNOLOGY CENTER 2800

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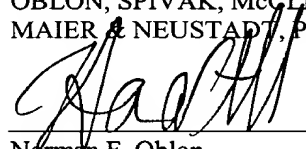
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The Fee has been calculated as shown below:

CLAIMS	CLAIMS REMAINING		HIGHEST NUMBER PREVIOUSLY PAID	NO. EXTRA CLAIMS	RATE	CALCULATIONS
TOTAL	15	MINUS	20	0	x \$18 =	\$0.00
INDEPENDENT	1	MINUS	3	0	x \$84 =	\$0.00
		<input type="checkbox"/> MULTIPLE DEPENDENT CLAIMS			+ \$280 =	\$0.00
		TOTAL OF ABOVE CALCULATIONS				\$0.00
		<input type="checkbox"/> Reduction by 50% for filing by Small Entity				\$0.00
		<input type="checkbox"/> Recordation of Assignment			+ \$40 =	\$0.00
		TOTAL				\$0.00

- ☒ A check in the amount of **\$930.00** is attached.
- ☒ Please charge any additional Fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.
- ☒ If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time may be charged to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

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214768US-0 PCT



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IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :

YASUJI HIRAMATSU ET AL ✓ : EXAMINER: SOWARD, I. M.

SERIAL NO: 09/926,297 ✓ :

FILED: DECEMBER 26, 2001 ✓ : GROUP ART UNIT: 2822

FOR: CERAMIC SUBSTRATE FOR A :  
SEMICONDUCTOR PRODUCTION/  
INSPECTION DEVICE

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AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

SIR:

Responsive to the Office Action dated July 17, 2002, Applicants respectfully request reconsideration of the above-identified application in view of the following amendment and remarks.

IN THE CLAIMS

Please amend the claims as follows:

sub B7  
A1  
1. (Amended) A ceramic heater for a semiconductor-producing/examining device having a heating element formed on a surface of a ceramic substrate or inside a ceramic substrate,